

Title:

Chemical Vapor Deposition Methods of Forming Barium Strontium Titanata

Comprising Dielectric Layers

Assignee:

Micron Technology, Inc.

References - See Attached Form PTO-1449

The attached form PTO-1449 is submitted in compliance with 37 CFR §1.56. No admission is made regarding whether any of the submitted references ' Respectfully submitted, RECEIVED TO 1700 is prior art. Copies of the references are attached.

Attorney:

J. Taylor, Ph/D.